ECLIPSE
L300N/L300ND
L200N/L200ND

Microscopes for Flat Planel Display
and Large Scale Integration Inspection

ECLIPSE

L300N

For ø300 mm wafer/
Episcopic optical contrast

L300ND

For 17-inch FPD/
Episcopic and Diascopic optical contrast

L200N

For ø200 mm wafer/
Episcopic optical contrast

L200ND

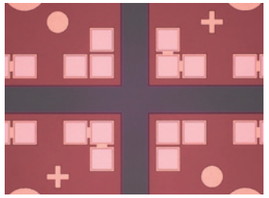
For ø200 mm wafer/
Episcopic and Diascopic optical contrast

Enhanced observation performance and operation

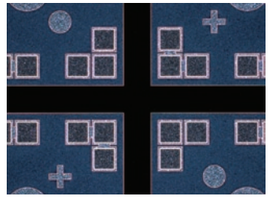
Epi-fluorescence observation widens inspection range—including 365 nm UV excitation

- Highly beneficial when inspecting semiconductor resist residues and organic electroluminescence displays.
- Various observation methods such as brightfield, darkfield, simple polarizing, and DIC are possible on all models.
- With the L300ND/L200ND, diascopic illumination capability adds the illumination through transparent substrates.

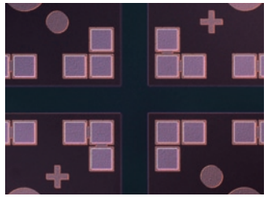
*L300N/L300ND/L200ND only



Brightfield observation of wafer pattern



Darkfield observation

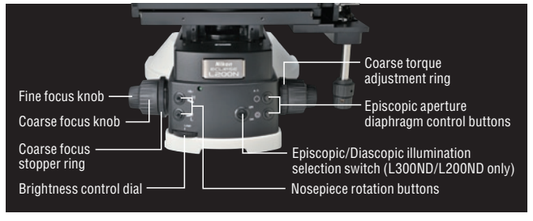


DIC observation

Epi-fluorescence observation of organic substance on wafer

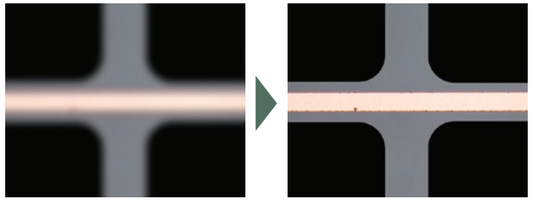
Front operation with easy access

- Minimizes fatigue during lengthy observations, maintaining a safer operator distance from the sample



Target for easier focusing

- Insert a focusing target in the optical path to easily focus on low-contrast samples, such as bare wafers.



Illumination

Stronger safeguard against contamination

- Antistatic coatings applied to the body, stage, eyepiece tube and other various controls
- Prevents damage to samples and contributes to higher yields

Observation at optimum eyepoint level

- Ultra-wide 25-mm field of view and eyepiece angle adjustment between 0 ° and 30 °
- Operators can adjust eyepoint level to ensure a comfortable viewing position

Fixed-position X-Y fine movement control

- Allows for stage movements and focusing to be carried out with ease

The X-Y fine movement controls are positioned close to the operator.

LED

Compact LED illuminators are power saving and achieve long life.

LV-LL LED Lamphouse

Intensilight

- Motorized mercury precentered fiber illuminator for epi-fluorescence observation, with variable light intensity and shutter control, provide excellent flexibility. Lamp centering and focus adjustment are not necessary.

*L300N/L300ND/L200ND only

Filter blocks

For epi-fluorescence observation

- EPI-FL UV-2A
- EPI-FL B-2A
- EPI-FL V-2A
- EPI-FL G-2A
- EPI-FL BV-2A

*L300N/L300ND/L200ND only. Only one cube is attachable.

Accessories

Nikon's CFI60 optical systems are highly evaluated for their unique concept of high NA combined with a long working distance. These lenses have been developed further and evolved achieving the apex in long working distance specifications, correct chromatic aberration, and an optimized lens weight.

Objective lenses

Standard objective lenses

Long WD · Semi-apo · Light weight · Fly-eye lens

TU Plan Fluor Series

EPI/BD 5x/10x/20x/50x/100x

Enable brightfield, darkfield, simple polarizing, sensitive polarizing, differential interference, and epi-fluorescence observations with just one lens. Achieves superior chromatic aberration performance with long working distance for all magnifications to adapt to any application.

*Brightfield observation (EPI) objective lens

Model	Magnification	NA	Working Distance (mm)
TU Plan Fluor EPI (brightfield type)	5×	0.15	23.5
	10×	0.30	17.5
	20×	0.45	4.5
	50×	0.80	1.0
	100×	0.90	1.0
TU Plan Fluor BD (brightfield/ darkfield type)	5×	0.15	18.0
	10×	0.30	15.0
	20×	0.45	4.5
	50×	0.80	1.0
	100×	0.90	1.0

Long working distance objective lenses

TU Plan ELWD Series

Long WD · Semi-apo · Light weight

EPI/BD 20x/50x/100x

With the phase Fresnel lenses, these objective lenses enable long working distances while offering higher level chromatic aberration correction than conventional objective lenses. This improves operability for samples with different heights.

*Brightfield observation (EPI) objective lens

Model	Magnification	NA	Working Distance (mm)
TU Plan EPI ELWD (brightfield type)	20×	0.4	19.0
	50×	0.6	11.0
	100×	0.8	4.5
TU Plan BD ELWD (brightfield/ darkfield type)	20×	0.4	19.0
	50×	0.6	11.0
	100×	0.8	4.5

Low-magnification objective lenses

T Plan EPI

Semi-apo · Wide field of view

EPI 1x/2.5x

Model	Magnification	NA	Working Distance (mm)
T Plan EPI (brightfield type)	1×	0.03	3.8
	2.5×	0.075	6.5

Apochromatic objective lenses

TU Plan Apo Series

Long WD · Apo · Light weight

EPI/BD 50x/100x/150x

By using phase Fresnel lenses, these objective lenses achieve significantly longer operating distances while maintaining the superior chromatic aberration performance of apochromatic lenses.

*Brightfield observation (EPI) objective lens

Model	Magnification	NA	Working Distance (mm)
TU Plan Apo EPI (brightfield type)	50×	0.8	2.0
	100×	0.9	2.0
	150×	0.9	1.5
TU Plan Apo BD (brightfield/ darkfield type)	50×	0.8	2.0
	100×	0.9	2.0
	150×	0.9	1.5

Other lenses

Lenses with correction mechanism

CFI L Plan EPI CR Series

EPI 20x/50x/100x

Model	Magnification	NA	Working Distance (mm)	Glass Thickness Correction Range (mm)
CFI L Plan EPI CR	20×	0.45	10.9-10.0	0-1.2
CFI L Plan EPI CR	50×	0.7	3.9-3.0	0-1.2
CFI L Plan EPI CRA	100×	0.85	1.2-0.85	0-0.7
CFI L Plan EPI CRB	100×	0.85	1.3-0.95	0.6-1.3

Microscope camera

Digital Sight 1000 NEW

Equipped with a 2 megapixel CMOS image sensor, it can capture full HD microscope images. By connecting a microscope to this camera and HDMI monitor, movies and images can be captured and saved onto a pre-inserted SD card in the camera.

2.0 megapixel · Color · Full HD

DS-Fi3

Three main features of the previous models, high-resolution, high sensitivity and low noise, and high-speed live display are offered in 1 camera.

5.9 megapixel · Color · High-resolution

DS-Ri2

Capable of expressing images as is, this microscope digital camera offers high resolution, color reproduction, and frame rate.

16.25 megapixel · Color · High-resolution

Frame Rate	30 fps (1920×1080)	30fps (1440×1024)	45fps (1636×1088)
Max Recordable Pixels	1920×1080	2880×2048	4908×3264

Imaging software NIS-Elements

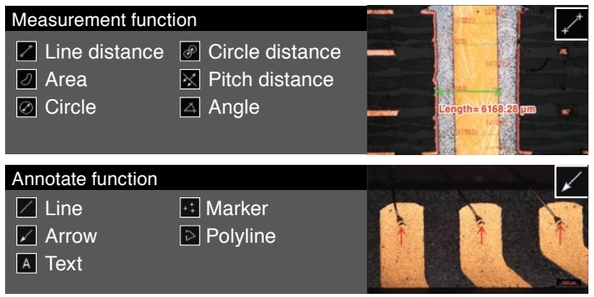
Using a tablet PC L

Simply installing NIS-Elements L on a tablet PC enables setting and control of Digital Sight 1000/DS-Fi3/DS-Ri2 microscope cameras, live image display, and image acquisition.

Using a desktop PC F · D · Br · Ar

A wide variety of tools

NIS-Elements L enables the conducting of simple measurements on images, with input of lines and comments. These can also be written onto and saved with the image, and measurement data can be output.



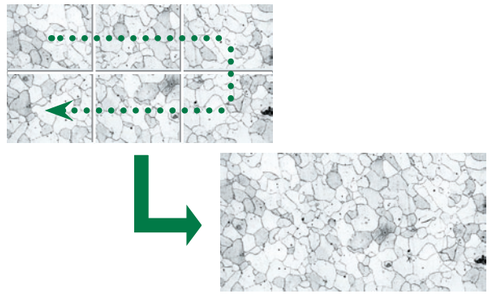
Scene Mode

Ten camera setting patterns for optimal color reproduction and contrast for each microscope light source, observation method and type of sample, as well as custom settings, can be selected.

- Wafer/IC
- Metal, Ceramic/Plastic
- Circuit board
- Flat Panel Display

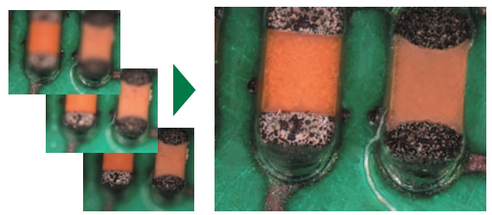
Image Stitching

Stitches together images acquired from multiple fields of view to create one image.



EDF (Extended Depth of Focus)

Create a single, all-in-focus image from images of differing focus.



*** See the "Digital Camera Digital Sight Series for Microscopes" catalog for details on Digital Sight features.**

Wafer loader NWL200

Combined with the NWL200 wafer loader, the ECLIPSE L200N meets requirements for wafer inspections.

Support for ultra-thin 100 µm wafers

• NWL200 series provides levels of safety and reliability that meet all requirements for inspection of the latest wafers.

Improved operability and high throughput

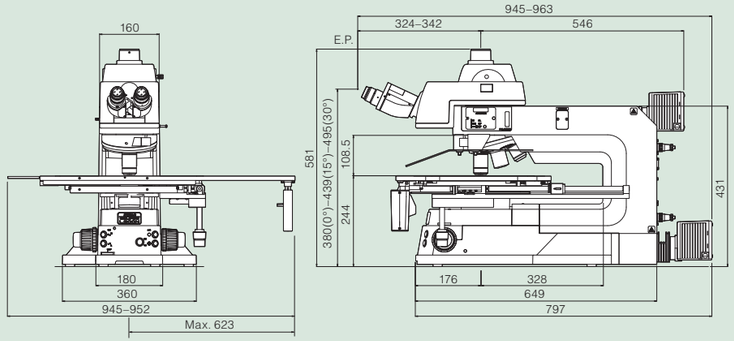
• Setting conditions, such as sampling and inspection patterns, and checking the operating status and content of errors can easily be done with the large LCD panel

• Comprehensive file management functions for carriers and samples are useful for automating inspections

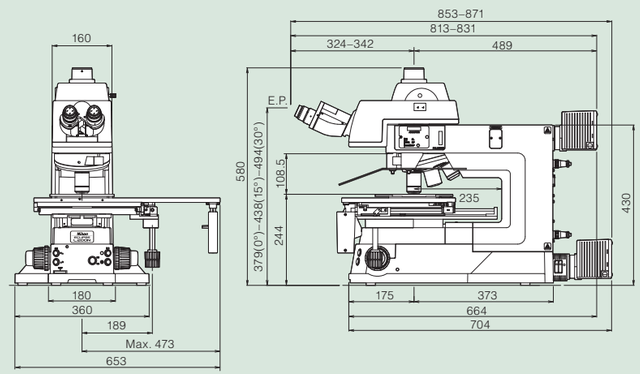
• Exceptionally fast elevator, and the loading and unloading of wafers with complete precision by the multi-arm system all contribute to an efficient wafer transfer and exchange

Dimensional diagram (Unit: mm)

ECLIPSE L300N/L300ND

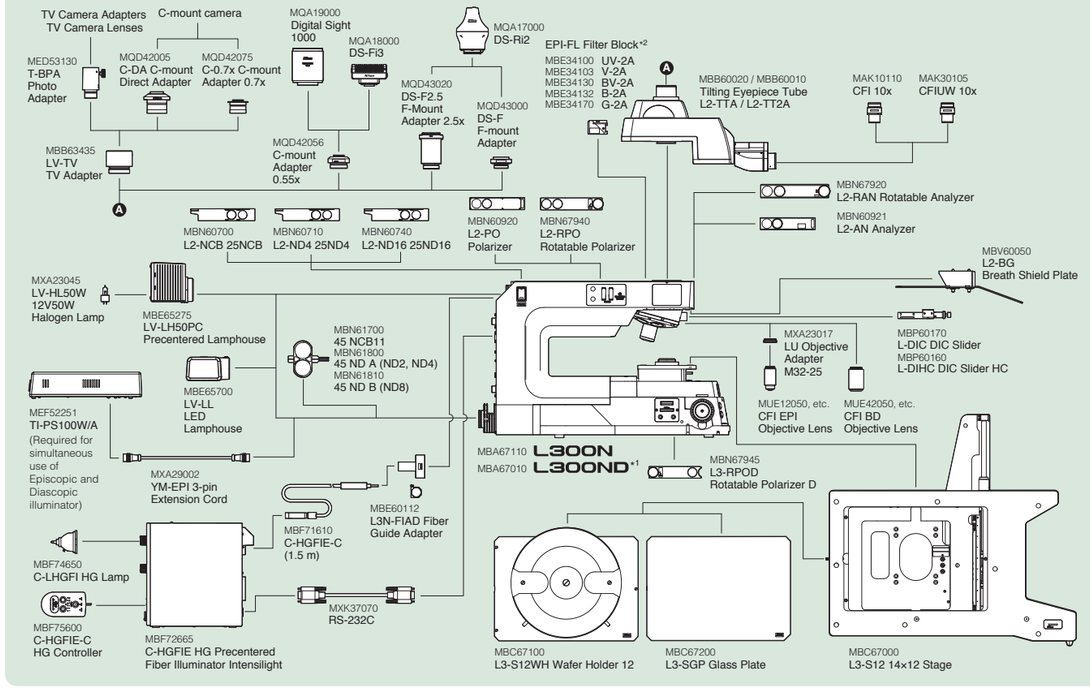


ECLIPSE L200N/L200ND

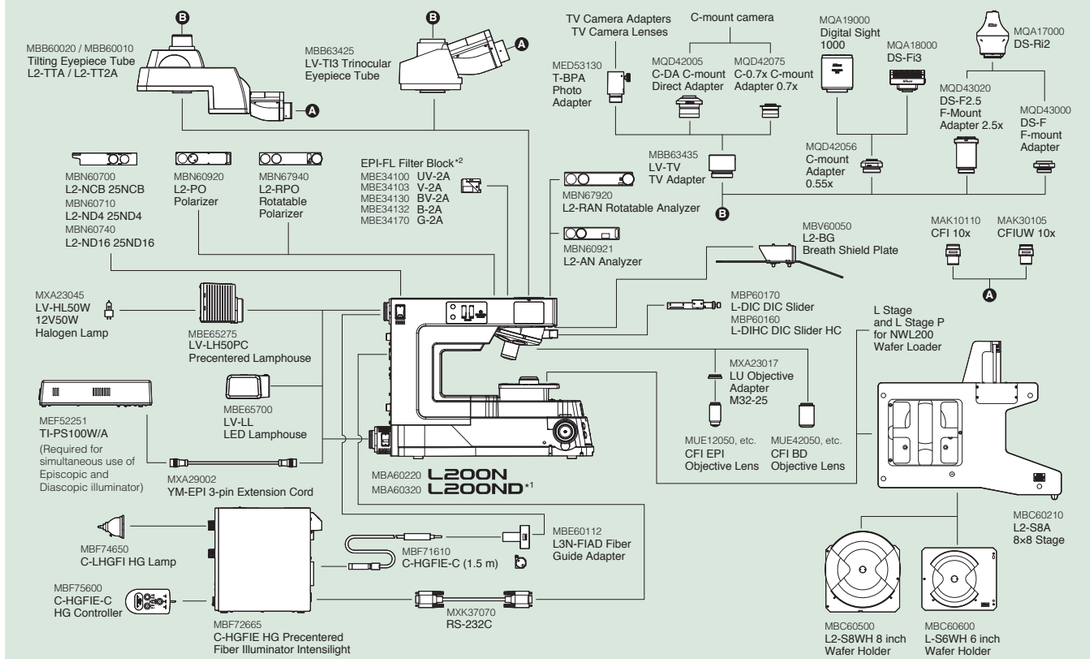


System diagram

ECLIPSE L300N/L300ND



ECLIPSE L200N/L200ND



*1 Diascopic illumination available only for L300ND and L200ND
*2 Epi-fluorescence observation available only for L300ND/L300N/L200ND

Specifications

		ECLIPSE L300N	ECLIPSE L200N	ECLIPSE L300ND	ECLIPSE L200ND
Illumination type		Episcopic		Episcopic/Diascopic	
Main body		Power sources for motorized control built in Motorized control for nosepiece, Light intensity control, Aperture diaphragm control			
Nosepiece		Motorized universal sextuple nosepiece			
	Centering Function	Yes	—	Yes	—
	EPI/DIA changeover	—	—	Yes	
Focusing mechanism	Cross travel	29 mm			
	Coarse	12.7 mm per rotation (torque adjustable, refocusing mechanism provided)			
	Fine	0.1 mm per rotation (in 1 µm increments)			
Episcopic illuminator		12V-50W halogen lamp light source built in, LV-LL LED Lamphouse Motorized aperture diaphragm (centerable), Fixed field diaphragm (with focus target) Pinhole slider (optional), Four ø25 mm filters (NCB11, ND16, ND4), Polarizer and Analyzer can be mounted Observation methods: Brightfield, Darkfield, Simple polarizing, DIC, Epi-fluorescence* (*L300N/L300ND/L200ND only)			
Diascopic illuminator		—		12V-50W halogen lamp light source built in, LV-LL LED Lamphouse Aperture diaphragm built in LWD condenser built in	
Interface		USB x 1, RS232C (for Intensilight) x 1			
Eyepiece tubes		L2-TT2A Ultra-widefield erect-image tilting trinocular eyepiece tube (tilt angle: 0-30 °) FOV: 22/25; Beam split ratio 100:0/20:80 L2-TTA Ultra-widefield erect-image tilting trinocular eyepiece tube (tilt angle: 0-30 °) FOV: 22/25; Beam split ratio 100:0/0:100 LV-TI3 Trinocular eyepiece tube (erect image) FOV: 22/25; Beam split ratio 100:0/0:100			
Eyepieces		CFI eyepiece lens series			
Objective lenses		CFI60-2/CFI60 system			
Stages		14 x 12 stage	L2-S8A 8 x 8 stage	14 x 12 stage	L2-S8A 8 x 8 stage
	Stroke	354 x 302 mm	205 x 205 mm	354 x 302 mm	205 x 205 mm
	Diascopic observation range	354 x 268 mm	150 x 150 mm	354 x 268 mm	150 x 150 mm
		Coarse/Fine-movement changeover possible Fixed-position X-Y fine-movement controls			
Antistatic mechanism		1000-10 V, within 0.2 sec			
Power consumption		1.2 A/90 W			
Weight (approx.)	Body only	40 kg	30 kg	40 kg	30 kg
	With L2-S8A 8 x 8 stage and L2-TTA eyepiece tube	45 kg	45 kg	45 kg	45 k

N.B. Export of the products* in this brochure is controlled under the Japanese Foreign Exchange and Foreign Trade Law. Appropriate export procedures shall be required in case of export from Japan.
*Products: Hardware and its technical information (including software)

⚠ WARNING	TO ENSURE CORRECT USAGE, READ THE CORRESPONDING MANUALS CAREFULLY BEFORE USING THE EQUIPMENT.

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